INNOVATION, DESIGN, AND THE ARTS GE MINOR

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The GE Minor in Innovation, Design, and the Arts is a hands-on minor where technology and aesthetics converge. Your coursework centers on historical, cultural, technological and artistic ideas and skills essential to expanding your creative and innovative potential. This transformational thinking complements any major and translates to any career path.

Students who are already completing the associated General Education (GE) Innovation, Design, and the Arts upper-division Pathway can earn the minor by taking six courses from different GE Areas. Students who complete all courses in the minor will meet the University's US Diversity (USD) and Global Cultures (GC) requirements, as well as at least one upper-division Writing (W) course.

Course Requirements for the Minor

The following courses, or their approved transfer equivalents, are required of all candidates for this minor.

Students can earn the minor by taking six courses from different GE Areas. Students who complete all courses in the minor will meet the University's US Diversity (USD) and Global Cultures (GC) requirements, as well as at least one upper-division Writing (W) course.

Course	Title	Units
Lower Division		
Arts (C1)		
Select one of the following:		3
ARTH 100	Art Appreciation: Multicultural Perspectives	
CAGD 110	Computer-Assisted Art I	
THEA 110	Introduction to Theatre Arts	
Social Sciences (D)	
JOUR 210	Pop Culture and Media Innovation	3
Lifelong Learning and Self-Development (E)		
MADT 102	Design Thinking	3
Upper Division		
Select three of the following: ¹		9
Scientific Inquiry and Quantitative Reasoning (UD-B)		
TECH 380W	Inventing the Future (W)	
Arts and Humanities (UD-C)		
LANC 340W	World Literature in Translation (W)	
Social Sciences (UD-D)		
CSCI 431W	Usability Engineering (W)	
MADT 307	Technology and Communication	
Total Units		18

¹ Choose three courses, each from a different GE area.